



10/081,818

**PATENT**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant: Jerome M. Eldridge et al. Examiner: Tu-Tu V. Ho  
Serial No.: 10/081,818 Group Art Unit: 2818  
Filed: February 20, 2002 Docket: 1303.045US1  
Title: ATOMIC LAYER DEPOSITION OF METAL OXIDE AND/OR LOW  
ASYMMETRICAL TUNNEL BARRIER INTERPOLY INSULATORS

**COMMUNICATION CONCERNING RELATED APPLICATIONS**

MS Issue Fee  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Noted,  
TH  
↓  
02/07  
Applicants would like to bring to the Examiner's attention the following related applications in the above-identified patent application:

<u>Serial/Patent No.</u>	<u>Filing Date/Issue Date</u>	<u>Attorney Docket</u>	<u>Title</u>
11508090	August 22, 2006	1303.024US4	FLOATING GATE STRUCTURES
11590363	October 31, 2006	1303.014US3	FLASH MEMORY WITH LOW TUNNEL BARRIER INTERPOLY INSULATORS
11565826	December 1, 2006	1303.141US2	HAFNIUM TITANIUM OXIDE FILMS

Continuations and divisionals may be later filed on the cases listed above, or cited to the Examiner in any previous Communication Concerning Related Applications. Applicants request that the Examiner review all continuations and divisionals of the above-listed or previously-cited patent applications before allowing the claims of the present patent application.

Respectfully submitted,

JEROME M. ELDRIDGE ET AL.

By Applicants' Representatives,

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Date

20 Dec '06

By

Timothy B. Clise  
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**CERTIFICATE UNDER 37 CFR 1.8:** The undersigned hereby certifies that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail, in an envelope addressed to: MS Issue Fee, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on this 20 day of December, 2006.

Name

KATHLEEN E. ROTHROCK

Signature

Kathleen E. Rothrock